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Hyeongtag Jeon is a professor in the Division of Materials Science and Engineering at Hanyang University. He received his B.S. and M.S. degrees from Hanyang University (1982, 1984) and Ph.D. degree from North Carolina State University (1991). He worked for Hyundai Electronics (former SK Hynix) as a senior researcher in diffusion team and moved to Hanyang University in 1992 as an assistant professor. His Ph.D. thesis was about thin film reaction of Ti-silicide and its characterization and he examined some retardation of phase transition of metal silicide depending on the film thickness. Since that time he has been working on various fields of thin film research such as high-k gate oxide, metal film deposition, metal nitride and etc. Especially he was interested in the surface reaction of thin film deposition and he concentrated in the field of atomic scale deposition which is atomic layer deposition. He started this ALD research in Korea in the mid of 1990 and he hosted AVS ALD 2002 in Korea and currently he is a chair of Korean ALD workshop started at 2005. And he received AVS ALD award in 2014 ALD meeting in Kyoto, Japan. He holds more than 50 Korean and international patents and has published more than 200 journal papers in the fields of semiconductor materials, 2D materials, flexible display passivation, and remote plasma ALD and CVD. He is Editor-in-Chief of Korean Journal of Materials Research, first Vice president of MRS-Korea, committee member of AVS ALD, member of MRS, AVS, ECS and many more.